

## A new insight on $I_{\text{RESET}}$ reduction of carbon-doped GST based PCM

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### Abstract

**In this paper, a detailed investigation of the electrical performances of phase-change memory devices integrating carbon-doped  $\text{Ge}_2\text{Sb}_2\text{Te}_5$  is reported. Compared to reference GST devices, up to 50% of current reduction is observed, with a programming window superior to two orders of magnitude. The RESET current reduction is attributed to an increase of the dynamic resistance of the device and to a decrease of the phase-change material thermal conductivity.**

### 1. Introduction

Thanks to its unique set of features such as short read and write times, multi-level capability and ease of integration, Phase-Change Memory (PCM) is receiving widespread interest as possible Flash memory technology replacement [1]. However, the high current required to switch from the low-resistive (SET) to the high-resistive (RESET) state,  $I_{\text{RESET}}$ , limits the minimum size of the selector element, and hence the maximum memory density [1]. Reduced  $I_{\text{RESET}}$  have been observed in large PCM devices integrating carbon-doped GST (GST-C) instead of pure GST [2]. Therefore, in this paper, the main electrical performances of lightly doped GST-C-based scaled devices are deeply investigated and the programming current reductions are explained using thermal conductivity measurement and TCAD simulations.

### 2. Device fabrication and electrical characterization

Devices here studied are wall-type PCM devices, having a doped-TiN heater with a nominal area ranging from 300 nm<sup>2</sup> to 900 nm<sup>2</sup> (Fig. 1) [3]. On top of the heater, a 70 nm-thick phase-change layer is deposited at room temperature by plasma-assisted co-sputtering from one target of pure GST and one target of pure carbon. Various carbon percentages were incorporated into GST (Table I).

Transition curves (R-I and I-V) of these PCM devices were obtained by measuring the resistance, sweeping the height of the voltage pulse through a load resistance,  $R_{\text{LOAD}}$ , of 1 K $\Omega$  (Fig. 1). Fig. 2 highlights the electrical performances of the 900 nm<sup>2</sup> devices as a function of the carbon content. It is worth noting that  $I_{\text{RESET}}$  is reduced up to about 50% when the carbon content increases up to 13.8%. Moreover, the overall power required to RESET ( $P_{\text{RESET}}$ ) and SET ( $P_{\text{SET}}$ ) the cell, and the energy needed to cycle the

cell one time,  $E_{\text{CYCLE}}$ , are also reduced (Table I). However, adding carbon reduces the memory window, i.e. the ratio between the RESET and SET state resistances (Fig. 2d).

The impact of scaling on  $I_{\text{RESET}}$  was studied on GST, GST-C0.75% and GST-C3.7% based PCM devices. Fig. 3a and b show that  $I_{\text{RESET}}$  linearly scales down with the heater area while the  $I_{\text{RESET}}$  reduction increases when the heater area decreases. As a result, carbon reduces  $I_{\text{RESET}}$  even for scaled PCM devices with a 300 nm<sup>2</sup> heater area. Note that the memory window is not affected by scaling (Fig. 3c).

### 3. Interpretation and discussion about $I_{\text{RESET}}$ reduction

It has been reported that the RESET behavior of GST-based PCM devices is controlled by few parameters: the resistance in the molten state called the device dynamic resistance,  $R_{\text{DYN}}$ , (Eq. 1) and the heat dissipation during melting (Eq. 2) [4]. Eq. 2 suggests that, in the steady-state, the decrease of  $P_{\text{RESET}}$  results from a modification of the thermal conductivity,  $\kappa$  (assuming a constant melting temperature). The  $\kappa$  of GST and GST-C3.7% have been measured using photothermal radiometry method [5] and a ratio of about 2.5 between the two values is obtained (Table II). Therefore, the decrease of  $\kappa$  contributes to the decrease of  $I_{\text{RESET}}$ . Furthermore, Fig. 4 shows that  $R_{\text{DYN}}$  increases with the carbon content meaning that in GST-C based devices,  $I_{\text{RESET}}$  decreases also thanks to the increase of  $R_{\text{DYN}}$ . Finally, using the PCM model of the Sentaurus Device tool from Synopsys [6] and the GST parameters given in [7], TCAD simulations were performed. A good agreement between the simulated and the measured transition curves of GST based devices is obtained (Fig. 5). Taking only into account the decrease of  $\kappa$  by a factor 2.5, a decrease of  $I_{\text{RESET}}$  is observed. Then, to fit the measured transition curves of GST-C3.7% based devices and get an  $I_{\text{RESET}}$  reduction equal to the measured one, the increase of  $R_{\text{DYN}}$  was added.

### 4. Conclusions

In this study, we show that the  $I_{\text{RESET}}$  and  $P_{\text{RESET}}$  of carbon-doped GST scaled PCM devices are reduced up to 50% while maintaining a memory window higher than two orders of magnitude. TCAD simulations and thermal conductivity measurement strongly suggest that these reductions could be explained by two main factors: an increase of the dynamic resistance of the device and a decrease of the thermal conductivity of the phase-change material.

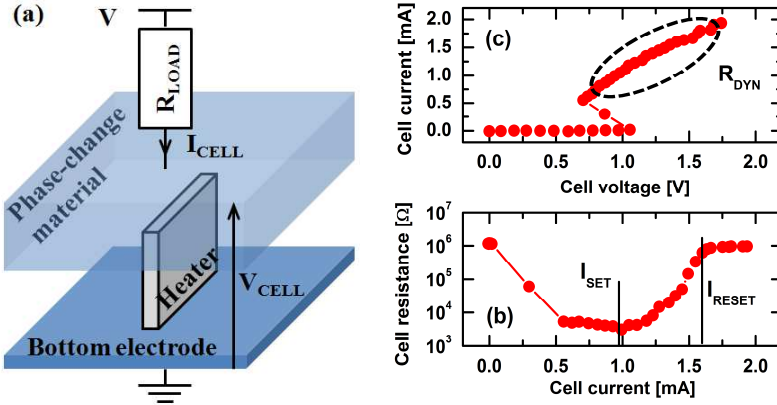


Fig. 1 Scheme of the wall-type device studied (a). Typical transition curves (R-I (b) and I-V (c) curves) of the GST-based PCM device with the 900 nm<sup>2</sup> heater.

Table I Electrical performances of the PCM devices with the 900 nm<sup>2</sup> heater.

Wafer number	Carbon content	$I_{\text{RESET}}$ & $I_{\text{SET}}$ reduction	$P_{\text{RESET}}$ & $P_{\text{SET}}$ reduction	$E_{\text{CYCLE}}$ reduction	Memory window
01	0 at. %	---	---	---	630
02	0.75 at. %	20% - 21%	22% - 25%	25%	708
03	1.5 at. %	23% - 22%	24% - 22%	24%	500
04	2.4 at. %	23% - 25%	25% - 24%	27%	432
05	3.7 at. %	25% - 22%	18% - 24%	22%	333
06	6.9 at. %	29% - 23%	22% - 34%	28%	482
07	13.8 at. %	48% - 42%	45% - 57%	50%	203

The carbon contents were measured using PIXE, NRA and RBS methods with an overall precision of  $\pm 0.5\%$ .

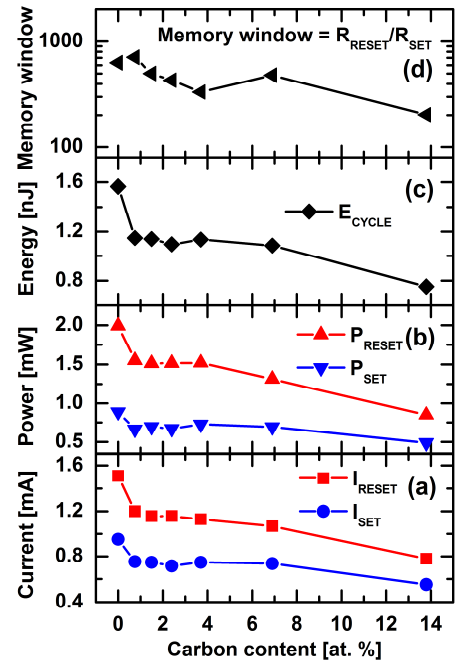


Fig. 2 Electrical performances of PCM devices with the 900 nm<sup>2</sup> heater as a function of the carbon content: programming currents (a) and powers (b), energy to RESET then SET the device (c), memory window (d).

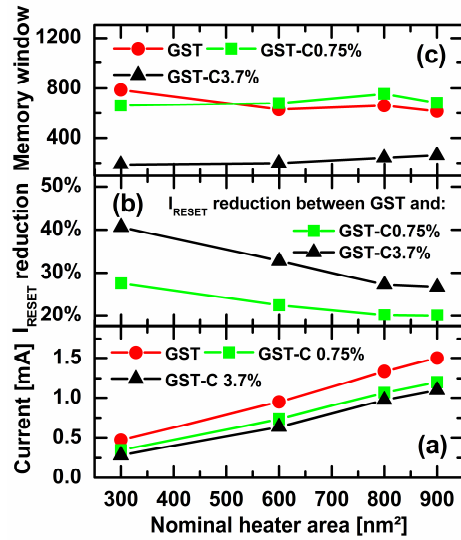


Fig. 3  $I_{\text{RESET}}$  (a),  $I_{\text{RESET}}$  reductions (b) and memory window (c) of GST, GST-C0.75% and GST-C3.7% based PCM devices as a function of the nominal heater area.

$$P_{\text{RESET}} = R_{\text{DYN}} \cdot I_{\text{RESET}}^2 \quad (1)$$

$$C \cdot \frac{\partial T}{\partial t} + \text{div}(-\kappa \cdot \text{grad}(T)) = \rho \cdot J^2 \quad (2)$$

Table II Ratio between the thermal conductivity of GST and the one of GST-C3.7% at various temperature

Temperature	$\kappa_{\text{GST}} / \kappa_{\text{GST-C3.7\%}}$
85°C	2.4
135°C	2.3
185°C	2.0
265°C	3.0
285°C	3.0

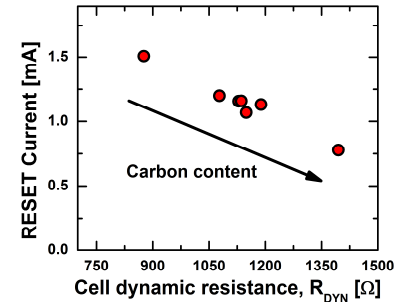
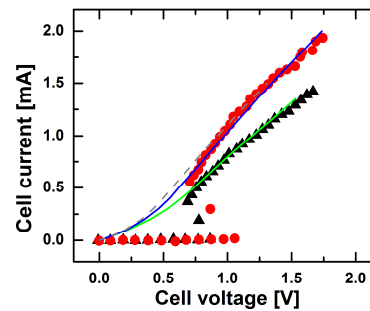


Fig. 4  $I_{\text{RESET}}$  of the GST and GST-C based PCM devices as a function of the cell dynamic resistance.

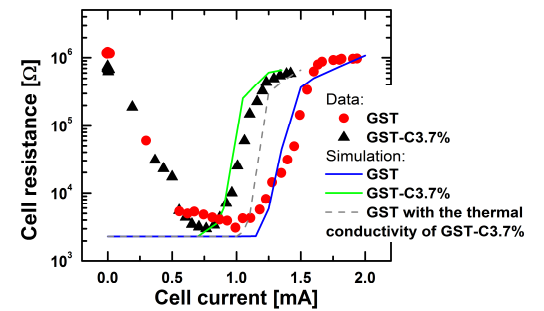


Fig. 5 Measured and simulated I-V (left) and R-I (right) curves of the GST and GST-C3.7% based PCM devices. The dash line represents the simulated transition curves of GST based devices with the phase-change material having the thermal conductivity of GST-C3.7%.

## References

- [1] G. W. Burr *et al.*, J. Vac. Sci. Technol. B, 28, pp. 223-262, 2010
- [2] Q. Hubert *et al.*, Proc. IMW, pp. 1-4, 2012
- [3] R. Annunziata *et al.*, IEDM Tech. Dig., pp. 1-4, 2009
- [4] V. Sousa *et al.*, Proc. E\*PCOS, 2012
- [5] J.-L. Battaglia *et al.*, J. Appl. Phys., 107, pp. 044314, 2010
- [6] B. Schmithusen *et al.*, Proc. SISPAD, pp. 57-60, 2008
- [7] A. Redaelli *et al.*, J. Appl. Phys., 103, pp. 111101, 2008